

| Power   Des   Des | agents) | 998 Title Current OR Current XRef Retrieval C 1 | 11 Tin-copper alloy 205/241 205/253; Yanada, electroplating bath 205/254 | loy plating bath and 205/252 f plating using the |                 | Water solu | teners 205/312 205/244 Helden, T<br>110y<br>or 106/1.18 106/1.19; Okuhama, | for zinc and zinc alloy Aqueous solutions for 106/1.18 106/1.19; Okuhama, Obtaining metals by 106/1.21; al. Electroplating baths salts 205/261 205/253; Wehlage, of aromatic hydroxy | Fater soluble brighteners 205/312 205/244 Helden, T for zinc and zinc alloy  Aqueous solutions for 106/1.18 106/1.19; Okuhama, obtaining metals by  Electroplating baths salts 205/261 205/253; Wehlage, of aromatic hydroxy 205/254 106/1.25; Bokisa, G electroplating thin and/or 205/254 205/253; Bokisa, G | ### ##################################   | For zinc and zinc alloy  Aqueous solutions for Aqueous solutions for Obtaining metals by Electroplating baths salts 205/261 205/253; Of aromatic hydroxy Plating bath and method for 205/254 205/253; Gallic acid as a combination 205/254 205/253; Alkoxylated diamane Surfactants in high-speed Surfactants in high-speed Surfactants in high-speed Surfactants in high-speed | mater soluble brighteners 205/312 205/244 Helden, for zinc and zinc alloy 105/1.18 105/1.19, Okuhama, Aqueous solutions for 105/1.18 106/1.21, al. obtaining metals by 106/253; Wehlage of aromatic hydroxy 205/251 205/253; Wehlage Plating bath and method for 205/254 205/253; Wehlage electroplating tin and/or 205/254 205/253; Gernon, Gallic acid as a combination 205/254 205/253; Gernon, antioxidant, grain refiner, 205/254 205/252; Opaskar, surfactants in high-speed 205/302 205/301 Polyoxyalklene compounds 205/253 106/1.05; Gernon, Gernon, Gernon, Gernon, Gernon, Gern |   | ### ### ##############################   |
|---|---------|---|--|--|-----------------|------------|--|--|--|--|---|--|---|--|
|   |         | t OR   Current XRef   Retrieval C               | 205/253; Yanada, 205/254   | 205/238 Saitoh,                                  | 205/244 Helden, |            | 106/1.19; Okuhama, 106/1.21;   | 8 116/1.19; Okuhama, 106/1.21; al. 205/253; Wehlage, 205/303;  | 8 106/1.19; Okuhama,<br>106/1.21; al.<br>205/253; Wenlage,<br>205/303; Ide/1.25; Sokisa, G   | 18 106/1.19; Okuhama, 106/1.21; al. 1 205/253; Rehlage, 205/253; Bokisa, G 205/253; Gernon, M 205/2730 | 18 106/1.19; Okuhama, 106/1.21; al. 1205/23; Wehlage, 205/303; Sokisa, G 205/253; Gernon, M 205/253; Gernon, M 205/352; Opaskar, 205/351  | 18 106/1.19;<br>106/253;<br>1 205/253;<br>1 205/303;<br>4 205/253;<br>4 205/253;<br>4 205/253;<br>4 205/253;<br>2 205/302;<br>2 205/301;<br>2 205/302;<br>2 205/301;<br>2 205/302;   | 18 106/1.19; Okuhama 106/1.21; al. 1 205/253; Wehlage 205/303; Boxisa, 4 205/253; Gernon, 205/302; Opaskar, 205/254; al. 205/254; al. 205/254; al. 205/254; al. 205/254; al. 205/254; al. | 18 106/1.19; Okuhama, Yo 106/1.21; al. 1 205/253; Wehlage, Th 205/253; Bokisa, Ge 205/253; Gernon, Mic 205/252; Opaskar, Vi 205/254; Gernon, Mic 205/255; Ge |

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